L	Hits	Search Text	DB	Time stamp
Number		•		
1	118	SOI with substrate and anneal\$ same	USPAT	2004/11/14
		silicide and second with anneal\$	1	19:17
2	1	("0000438").PN.	USPAT	2004/11/14
		,		19:16
3	116	SOI with substrate and anneal\$ same	USPAT	2004/11/14
		silicide and second with anneal\$ and		19:17
		method		
4	21	SOI with substrate and anneal\$ same	USPAT	2004/11/14
1		silicide and second with anneal\$ and		19:21
		method and insulating with hole		
5	1	("6624010").PN.	USPAT	2004/11/14
	_	(0021020 / 12111	1	19:23
6	2	(("6174806") or ·("6423599")).PN.	USPAT	2004/11/14
١ ١	2	((01/4000 / 01 (0123033 //.1		19:23